



# Contact Angle measurements on thin films

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### Outline

- Nanoparticle metal-polymer composite thin films
- Contact angle machine
- Temporal evolution of CA after acid cleaning
- Plasma cleaning
- CA measurements on different functional groups
- CA mapping
- Conclusions



#### Nanoparticle metal-polymer composite thin films





#### Applications

Efficiency improvement in photovoltaic cells



Matheu et al., Appl. Phys. Lett. 93, 113108 (2008)







#### **Films Preparation**





# **Quality Control - AFM**



• High resolution: Till a few atomic distances

#### BUT

• Ex-Situ measurement: No possibility to follow the evolution of Gold clusters on the polymer





#### **Quality Control - GISAXS**





### **Contact Angle machine**

Necessity to control acid cleaning and polymer deposition quality





#### What is a Contact Angle?

- Angle measured at the solid/vapour/liquid interface
- Linked to surface energy
- Strongly dependent on the surface arrangement





#### **Temporal evolution of CA after acid cleaning**

Acid Cleaned Silicon sample, kept in low pressure and humidity conditions



#### **Temporal evolution of CA after acid cleaning**



#### **Plasma Cleaning**



Oxygen at low pressure is ionized



Very effective in the breaking of most organic bonds



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#### **Plasma Cleaning**

Siloxane on Silicon substrate, Plasma cleaning at the lower intensity



#### **CA Measurements on different Functional Groups**





# **CA Mapping**



- > To obtain a measure of the sample uniformity
- > To increase the statistics, reducing the error
- > To obtain a "roughness" profile of the surface





# Conclusions

- There is not a clear difference in hydrophilicity between samples stored in room and controlled conditions.
- Plasma cleaning is a suitable way to tune the contact angle. Further analysis can be performed with different materials.
- A CA mapping procedure has been successfully implemented, allowing to have more precise measurements.
- A characterization of different Functional Groups on a Silicon substrate has been performed.



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